EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S177	90615	(terpinene limonene terpene cyclohexane trimethylcyclohexane cyclooctadiene dimethylcyclooctadiene camphene adamantane tricyclodecane butadiene decahydronaphthelene Tricyclodecane alphaterpinene norcamphene biacetylene butadiine butadiyne dekalin decalin bicyclodecane "C.sub.10 H.sub.16" "C.sub.10H.sub.16" "C.sub.10 H.sub.18" "C.sub.10H. sub.18" "C.sub.9 H.sub.18" "C. sub.9H.sub.18" "C.sub.6 H. sub.12" "C.sub.6H.sub.12" "C. sub.4 H.sub.6" "C.sub.4H.sub.6") and (UV ultra adj violet ultraviolet)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S178	1586	(terpinene limonene terpene cyclohexane trimethylcyclohexane cyclooctadiene dimethylcyclooctadiene camphene adamantane tricyclodecane butadiene decahydronaphthelene Tricyclodecane alphaterpinene norcamphene biacetylene butadiine butadiyne dekalin bicyclodecane "C.sub.10 H. sub.16" "C.sub.10H.sub.16" "C. sub.10 H.sub.18" "C.sub.10H. sub.18" "C.sub.9 H.sub.18" "C. sub.9H.sub.18" "C.sub.6 H. sub.12" "C.sub.6H.sub.12" "C. sub.4 H.sub.6" "C.sub.4H.sub.6") same (dry drying dried evaporat $4 vaporiz$6 remov$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S179	4518	(porous pore porosity porogen micropor$6 nanopor$6 void) same (dry drying dried evaporat $4 vaporiz$6 remov$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36

S180	141	S177 and ((diethoxy adj methyl methyl adj diethoxy tetra adj ethoxy dimethyl adj diethoxy dimethyl adj diethoxy dimethyl adj ethoxy trimethyl adj phenoxy) adj silane tetra adj ethyl adj oxysilicate (hexa adj methyl tetra adj methyl) adj disiloxane octa adj methyl adj trisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S181	13727	S177 and (diethoxymethylsilane methyldiethoxysilane DEOMS MDEOS tetraethoxysilane tetraethyloxysilicate TEOS dimethyldiethoxysilane DMDEOS dimethyldiethoxysilane DMDMOS dimethylethoxysilane DMDEOS triethoxysilane trimethylphenoxysilane TMPOS phenoxysilane POS hexamethyldisiloxane HMDS tetramethyldisiloxane TMDS octamethyltrisiloxane OMTS)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S182	1249	S177 and ((diethoxymethyl methyldiethoxy tetraethoxy dimethyldiethoxy dimethyldiethoxy dimethylethoxy triethoxy trimethylphenoxy phenoxy) adj silane tetraethyl adj oxysilicate (hexamethyl tetramethyl) adj disiloxane octamethyl adj trisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S183	421	(S180 or S181 or S182) and (S178 or S179)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S184	403249	(terpinene limonene terpene cyclohexane trimethylcyclohexane cyclooctadiene dimethylcyclooctadiene camphene adamantane tricyclodecane butadiene decahydronaphthelene Tricyclodecane alphaterpinene norcamphene biacetylene butadiine butadiyne dekalin decalin bicyclodecane "C.sub.10 H.sub.16" "C.sub.10H.sub.16" "C.sub.10 H.sub.18" "C.sub.10H.sub.18" "C.sub.9 H.sub.18" "C.sub.9H.sub.18" "C.sub.6 H.sub.12" "C.sub.6H.sub.12" "C.sub.4 H.sub.6" "C.sub.4H.sub.6")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36

S185	46	S184 same ((diethoxy adj methyl methyl adj diethoxy tetra adj ethoxy dimethyl adj diethoxy dimethyl adj diethoxy dimethyl adj ethoxy trimethyl adj phenoxy) adj silane tetra adj ethyl adj oxysilicate (hexa adj methyl tetra adj methyl) adj disiloxane octa adj methyl adj trisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S186	2155	S184 same (diethoxymethylsilane methyldiethoxysilane DEOMS MDEOS tetraethoxysilane tetraethyloxysilicate TEOS dimethyldiethoxysilane DMDEOS dimethyldiethoxysilane DMDMOS dimethylethoxysilane DMDEOS triethoxysilane trimethylphenoxysilane TMPOS phenoxysilane POS hexamethyldisiloxane HMDS tetramethyldisiloxane TMDS octamethyltrisiloxane OMTS)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S187	396	S184 same ((diethoxymethyl methyldiethoxy tetraethoxy dimethyldiethoxy dimethyldiethoxy dimethylethoxy triethoxy trimethylphenoxy phenoxy) adj silane tetraethyl adj oxysilicate (hexamethyl tetramethyl) adj disiloxane octamethyl adj trisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S188	63	S183 and (S185 or S186 or S187)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S189	395	S187 not S188	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:36
S190	8	S188 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:40
S191	36	S189 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:41
S192	1	S191 and ("427"/$.CCLS.or "438"/$.CCLS.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:42

S193	35	S191 not S192	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:47
S194	395	S187 not S188	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S195	41	S188 and @AD>="20021114"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S196	194	S194 and @AD>="20021114"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S197	9	S196 and ("427"/$.CCLS. or "438"/$.CCLS.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S198	22	S188 and @AD<"20021114"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S199	204	S194 and @AD<"20021114"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S200	14	S199 and ("427"/$.CCLS. or "438"/$.CCLS.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S201	190	S199 not S200	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S202	15	S198 and (porous pore porosity porogen micropor$6 nanopor$6 void)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S203	5	S200 and (porous pore porosity porogen micropor$6 nanopor$6 void)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48

S204	30	S201 and (porous pore porosity porogen micropor$6 nanopor$6 void)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S205	7	S198 not S202	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S206	9	S200 not S203	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S207	160	S201 not S204	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S208	8684	(Methane ethane propane butane benzene hexane hydrocarbon C10H16 C10H18 "CH.sub.4" CH4 "C.sub.2 H. sub.6" "C.sub.2H.sub.6" C2H6 C9H18 "C.sub.6 H.sub.6" "C. sub.6H.sub.6" C6H12 "C.sub.3 H. sub.8" "C.sub.3H.sub.8" C3H8) same (dry drying dried evaporat $4 vaporiz$6 remov$4 porous pore porosity porogen micropor $6 nanopor$6 void) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S209	17	S208 same ((diethoxymethyl methyldiethoxy tetraethoxy dimethyldiethoxy dimethyldiethoxy dimethylethoxy triethoxy trimethylphenoxy phenoxy) adj silane tetraethyl adj oxysilicate (hexamethyl tetramethyl) adj disiloxane octamethyl adj trisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S210	55	S208 same (diethoxymethylsilane methyldiethoxysilane DEOMS MDEOS tetraethoxysilane tetraethyloxysilicate TEOS dimethyldiethoxysilane DMDEOS dimethyldiethoxysilane DMDMOS dimethylethoxysilane DMDEOS triethoxysilane trimethylphenoxysilane TMPOS phenoxysilane POS hexamethyldisiloxane HMDS tetramethyldisiloxane TMDS octamethyltrisiloxane OMTS)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48

S211	28	S208 same (organosilane organosiloxane organodisiloxane (organo alkoxy) adj silane alkoxysilane (organo alkyl) adj (siloxane disiloxane) alkylsiloxane alkyldisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S212	90	S209 or S210 or S211	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S213	19	S212 and (porous pore porosity porogen micropor$6 nanopor$6 void)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S214	90	S212 and (UV ultra adj violet ultraviolet "U.V.")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S215	66	S214 not (S213 or S195 or S197 or S202 or S203 or S204 or S205 or S206 or S207)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S216	18	S213 not (S195 or S197 or S202 or S203 or S204 or S205 or S206 or S207)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S217	29949	(Solvent C4 C1 C2 C6 C9 C8 C7 C3 C5 C10 C11 C12 C13) same (dry drying dried evaporat$4 vaporiz$6 remov$4 porous pore porosity porogen micropor$6 nanopor$6 void) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S218	1	S217 same ((diethoxy adj methyl methyl adj diethoxy tetra adj ethoxy dimethyl adj diethoxy dimethyl adj diethoxy dimethyl adj ethoxy trimethyl adj phenoxy) adj silane tetra adj ethyl adj oxysilicate (hexa adj methyl tetra adj methyl) adj disiloxane octa adj methyl adj trisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48

S219	20	S217 same ((diethoxymethyl methyldiethoxy tetraethoxy dimethyldiethoxy dimethyldiethoxy dimethylethoxy triethoxy trimethylphenoxy phenoxy) adj silane tetraethyl adj oxysilicate (hexamethyl tetramethyl) adj disiloxane octamethyl adj trisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S220	162	S217 same (diethoxymethylsilane methyldiethoxysilane DEOMS MDEOS tetraethoxysilane tetraethyloxysilicate TEOS dimethyldiethoxysilane DMDEOS dimethyldiethoxysilane DMDMOS dimethylethoxysilane DMDEOS triethoxysilane trimethylphenoxysilane TMPOS phenoxysilane POS hexamethyldisiloxane HMDS tetramethyldisiloxane TMDS octamethyltrisiloxane OMTS)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S221	85	S217 same (organosilane organosiloxane organodisiloxane (organo alkoxy) adj silane alkoxysilane (organo alkyl) adj (siloxane disiloxane) alkylsiloxane alkyldisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S222	72	(S218 or S219 or S220 or S221) and (porous pore porosity porogen micropor$6 nanopor$6 void) and (UV ultra adj violet ultraviolet "U.V.")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S223	61	S222 not (S215 or S216 or S195 or S197 or S202 or S203 or S204 or S205 or S206 or S207)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:48
S224	7	S223 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:52
S225	4	S215 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:52
S226	6	S216 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:53

S227	26229	(427/508-522,541-542,552-559,561-563,569-579,249.1-255.395,430.1).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/21 15:57
S228	4518	(porous pore porosity porogen micropor$6 nanopor$6 void) same (dry drying dried evaporat $4 vaporiz$6 remov$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S229	1623	(terpinene limonene terpene cyclohexane trimethylcyclohexane cyclooctadiene dimethylcyclooctadiene camphene adamantane tricyclodecane butadiene decahydronaphthelene dendrimers hyper adj branch$3) same (dry dried drying evaporat $4 vaporiz$6 remov$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S230	147	S227 and (S228 or S229)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S231	576	((porous pore porosity porogen micropor$6 nanopor$6 void) same (dry drying dried evaporat $4 vaporiz$6 remov$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))) same (dielectric adj constant silica BSG borosilicate BPSG silicon adj (oxide dioxide carbide oxynitride carbonitride fluorosilicate) DLC diamond diamondlike)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57

S232	348	((terpinene limonene terpene cyclohexane trimethylcyclohexane cyclooctadiene dimethylcyclooctadiene camphene adamantane tricyclodecane butadiene decahydronaphthelene dendrimers hyper adj branch$3) same (dry drying dried evaporat $4 vaporiz$6 remov$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer))) same (dielectric adj constant silica BSG borosilicate BPSG silicon adj (oxide dioxide carbide oxynitride carbonitride fluorosilicate) DLC diamond diamondlike)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S233	882	(S231 or S232)not S230	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S234	336	S233 and (CVD LPCVD PECVD plasma chemical adj vapor$7)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S235	546	S233 not S234	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S236	8363	(Tricyclodecane alphaterpinene norcamphene biacetylene butadiine butadiyne dekalin bicyclodecane "C.sub.10 H. sub.16" "C.sub.10H.sub.16" "C. sub.10 H.sub.18" "C.sub.10H. sub.18" "C.sub.9 H.sub.18" "C. sub.9H.sub.18" "C.sub.6 H. sub.12" "C.sub.6H.sub.12" "C. sub.4 H.sub.6" "C.sub.4H.sub.6")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S237	98	(S227 and S236) not (S230 or S234 or S235)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57

S238	1073	S236 and (diethoxymethylsilane methyldiethoxysilane DEOMS MDEOS tetraethoxysilane tetraethyloxysilicate TEOS dimethyldiethoxysilane DMDEOS dimethyldiethoxysilane DMDMOS dimethylethoxysilane DMDEOS triethoxysilane trimethylphenoxysilane TMPOS phenoxysilane POS hexamethyldisiloxane HMDS tetramethyldisiloxane TMDS octamethyltrisiloxane OMTS)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S239	73	S236 and ((diethoxymethyl methyldiethoxy tetraethoxy dimethyldiethoxy dimethyldiethoxy dimethylethoxy triethoxy trimethylphenoxy phenoxy) adj silane tetraethyl adj oxysilicate (hexamethyl tetramethyl) adj disiloxane octamethyl adj trisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S240	9	S236 and ((diethoxy adj methyl methyl adj diethoxy tetra adj ethoxy dimethyl adj diethoxy dimethyl adj diethoxy dimethyl adj ethoxy trimethyl adj phenoxy) adj silane tetra adj ethyl adj oxysilicate (hexa methyl tetra adj methyl) adj disiloxane octa adj methyl adj trisiloxane)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S241	20	S237 and (S238 or S239 or S240)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:57
S242	78	S237 not S241	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 15:59
S243	4	S241 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:00
S244	6	S242 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:00

S245	23	((S236) same (dry drying dried evaporat$4 vaporiz$6 remov$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ". angstrom." excimer))) same (dielectric adj constant silica BSG borosilicate BPSG silicon adj (oxide dioxide carbide oxynitride carbonitride fluorosilicate) DLC diamond diamondlike)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:02
S246	7	(S245) not (S230 or S234 or S235 or S237)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:02
S247	1	S246 and (S238 or S239 or S240)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:03
S248	15	S245 and (S238 or S239 or S240)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:04
S249	8	S245 not S248	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:05
S250	0	S247 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:05
S251	0	S248 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:05
S252	1	S249 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:05
S253	0	(S230 and @pd>"20070809") and (S238 or S239 or S240)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:17
S254	7	(S245) not (S230 or S234 or S235 or S237)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:20

S255	1560	S236 and (CVD LPCVD PECVD plasma chemical adj vapor$7)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:20
S256	331	S255 and (S238 or S239 or S240)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:20
S257	304	S256 not (S237 or S245 or S254)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:20
S258	10	S257 and ((porous pore porosity porogen micropor$6 nanopor$6 void multiphas$5) same (dry drying dried evaporat$4 vaporiz $6 remov$4) same (UV ultra adj violet ultraviolet wavelengh near3 (nm nanometer nmeter angstrom ".angstrom." excimer)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:20
S259	2	S258 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:21
S260	302	S257 not S259	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:24
S261	31	S260 and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:24
S262	17	(S213 or S195 or S197 or S202 or S203 or S204 or S205 or S206 or S207) and @pd>"20070809"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:43
S263	53	(S224 or S225 or S226 or S243 or S244 or S252 or S259 or S261) Not (S190 or S191 or S262)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/21 16:50

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